



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

April 15, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

Cut Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

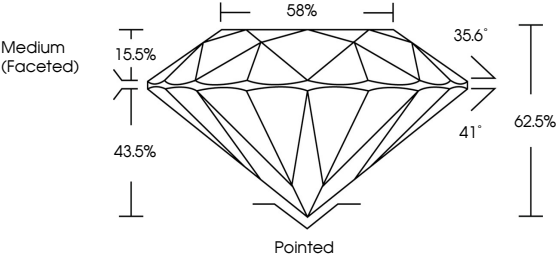
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

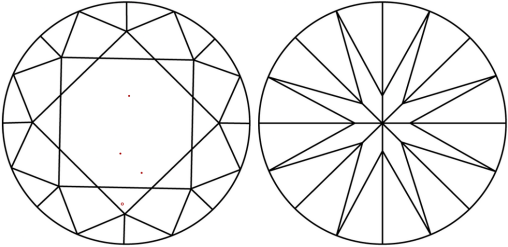
LG783617795

Report verification at [igi.org](#)

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

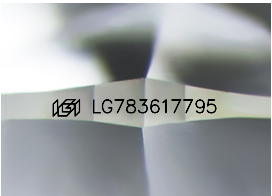
D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used



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LG783617795

LABORATORY GROWN DIAMOND

ROUND BRILLIANT

7.31 - 7.33 X 4.57 MM

1.52 CARAT

E

VS 1

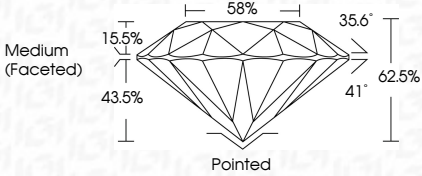
IDEAL

EXCELLENT

EXCELLENT

NONE

IGI LG783617795





IGI

April 15, 2026

IGI Report No LG783617795

ROUND BRILLIANT

7.31 - 7.33 X 4.57 MM

1.52 CARAT

E

VS 1

IDEAL

62.5%

58%

Medium (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

IGI LG783617795

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